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Thermolysis of methoxy-substituted polysilanes*

In a previous report¹ we have described the base-catalyzed sillicon-silicon silicon-methoxy redistribution with substituted polysilanes. In the case of dimethyltetramethoxydisilane (I), the base-catalyzed redistribution was extren rapid at 130°, and within five minutes 98% of the theoretical methyltrimethe silane was obtained based on the stoichiometry in equation (1).

Me Me $(MeO)_2Si-Si(OMe)_2 \longrightarrow MeSi(OMe)_3 + [(MeO)SiMe]_n$ Ι

During the course of this latter investigation we observed that I undergo thermal redistribution in the absence of added base. Thus, when I was heated at 1 for 40 h, the products were methyltrimethoxysilane, tris(methyldimethoxysil methylsilane (II) and a viscous nonvolatile polysilane residue (III)**.

Me $I \xrightarrow{d} MeSi(OMe)_2 + [(MeO)_2Si]_3SiMe + "higher polysilane residue"$ TT III

Compound II was isolated from the residue III by distillation; b.p. 110-111°, mm, vield 20-25 % (Anal. Found: C, 33.5, 33.8; H, S.53, S.60; Si, 30.8 %, mol. wt. by mass spectroscopy, calcd. for $C_{10}H_{20}Si_4O_6$: C, 33.5; H, S.40; Si, 31.3%; mol.

^{*} Redistribution studies with polysilanes. Part II. For Part I see ref. 1. Presented in at the Division of Organic Chemistry, 150th National Meeting of the American Chemical Soci Atlantic City, New Jersey, Sept. 13-17, 1965. Abstracts, p. 76S.

^{*} The reaction proceeds equally well in metal, Vycor* or acid-washed glass tubes.

358.) Assignment of the unusual branched-chain structure II rather than the linear structure IV did not follow straightforwardly from the spectral properties.

The UV-spectrum showed no λ_{max} above 200 m μ , consistent with the results previously reported² for other branched-chain derivatives. The absence of an absorption in the 235-40 m μ region^{1,3} argued strongly against the linear structure IV. However, the NMR spectrum^{*} showed singlets at 6.51 and 9.78 τ (ratio 3:2) assigned to the MeOSi and MeSi protons, respectively. The NMR results are consistent with structure II only if a fortuitous equivalence in chemical shift of the two MeSi groups is assumed. The necessity of this assumption prompted us to obtain chemical evidence for the assignment of structure II.

Compound I was converted to the permethylated derivative V in an overall yield of 87% (3). Compound V (b.p. 94-5°/8 mm) was purified by VPC and isolated as a low-melting waxy solid.

$$I \xrightarrow{CH_{3}COC1} (Cl_{2}Si)_{3}SiMe \xrightarrow{MeMgBr} (Me_{3}Si)_{3}SiMe \qquad (3)$$

The UV spectrum of V showed no λ_{max} above 200 m μ , consistent with a branchedchain structure. The NMR spectrum showed the expected singlets at 9.86 and 9.95 τ assigned to the Me₃Si and MeSi protons, respectively (ratio 3:r). Finally, samples of V prepared by two previously reported procedures, (4)⁴ and (5)⁵, were identical in all respects to that prepared according to (3).

$$(Me_3Si)_4Si \xrightarrow{MeLi} (Me_3Si)_3SiLi \xrightarrow{Me_2SO_4} V$$
 (4)

$$MeSiCl_3 + 3 Me_3SiCl \xrightarrow{Li} V$$
(5)

It is interesting to compare the thermal reactivity of I with that previously reported for other organodisilanes. The isomerization of hexamethyldisilane has been reported⁶ to occur at 600° and, in general, pentamethyldisilanyl compounds and methylpolysilanes have been observed⁷ to have good thermal stability. Pentamethyldisilanyl cyanide, a notable exception, has been reported⁷ to undergo a redistribution reaction at 175°.

We observed that other methoxy-substituted polysilanes also undergo this thermal redistribution. When 1,2-dimethoxytetramethyldisilane (VI) was heated at

^{*} All NMR spectra were determined at 50 cps with a Varian A60 Spectrometer as ca. 10% solutions in carbon tetrachloride using tetramethylsilane as internal standard.

225° ($t_{i_1} \cong 2$ h) the products were dimethyldimethoxysilane and the homologous series of α, ω -dimethoxypermethylated polysilanes (VII). At a somewhat higher temperature (275°), the trisilane VIIa gave dimethyldimethoxysilane and higher members of the

$$MeO(SiMe_2)_2OMe \longrightarrow Me_2Si(OMe)_2 \div MeO(SiMe_2)_nOMe$$
(6)
VII a, $\pi = 3$
b, $\pi = 4$
c, $\pi = 5$

polysilane series VII. While these limited relative reactivities parallel those observed¹ in the base-catalyzed reactions, the distribution of products is quite different. Whereas base-catalysis gave mainly the trisilane VIIa from VI and the pentasilane VIIc from VIIa, the thermolysis gives a more random distribution of the series VII.

Although the nature of these reactions is uncertain, an α -elimination to give a divalent silicon (silene) intermediate (7), followed by a series of insertion reactions starting with the disilane (8) seems quite probable. A similar pathway is envisioned for the thermolysis of I. When the disilane VI was heated at 225° in the presence of

$$MeO(SiMe_2)_2OMe \longrightarrow Me_2Si(OMe)_2 \rightarrow Me_2Si:$$

$$VI$$

$$(7)$$

$$Me_2Si: + VI \longrightarrow MeO(SiMe_2)_nOMe$$

$$VII$$
(8)

excess diphenylacetylene, I,I,4,4-tetramethyl-2,3,5,6-tetraphenyl-I,4-disilacyclohexadiene (VIII) was isolated in a 49% yield, m.p. 323-5° (lit.⁸ 324-6°, mixed m.p.)*. Compound VIII has been isolated in previously reported reactions believed to involve dimethylsilylene.** Experiments designed to answer these interesting questions will

be part of our continuing study of the thermal reactions of these and related polysilanes.

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^{*} We wish to thank Professor H. Gilman for providing us with a known sample of VIII. Our sample of VIII was also shown to be identical with a sample prepared (see ref. 9) by the method of Volpin, *et al.*¹⁰.

^{**} See ref. S and pertinent references cited therein.

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